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Interaction of Highly Charged Ions (HCl) with matter

or

What can you do with cold HCl?

J. Burgdörfer, C. Lemell, M. Seliger

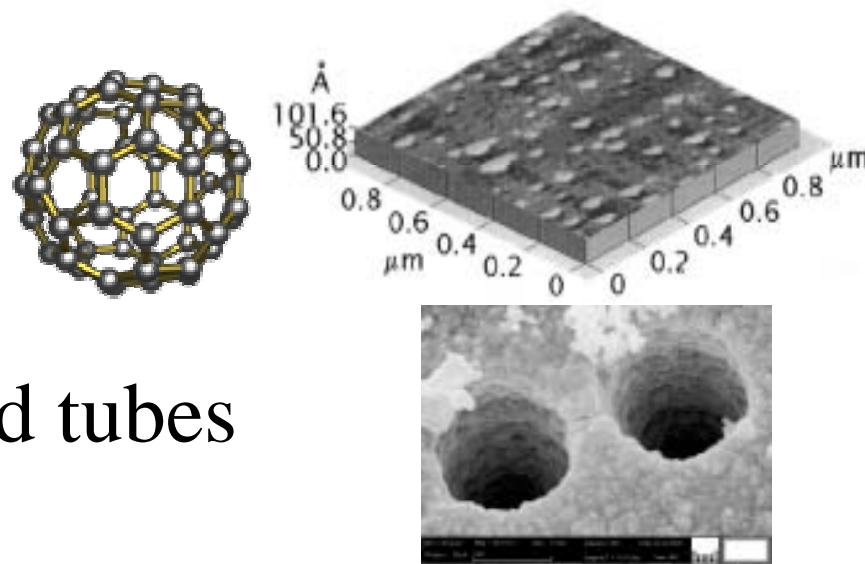
L. Wirtz, K. Tökesi, W. Palfinger

Inst. for Theoretical Physics, Vienna University of Technology

HCI – Matter Interactions at Low Velocities

- **(Condensed) Matter:**

- Clusters
- Surfaces
- (Nano-) Capillaries and tubes



- **Low Velocities:**

- $E_{pot} \gg E_{kin}$
- Long interaction times $\tau = \frac{\langle r \rangle}{v} \approx 100 \text{ a.u.} \approx 2.5 \text{ fs}$
short laser pulses
- Strong fields $F \approx \frac{q}{\langle r \rangle^2} \geq 1$

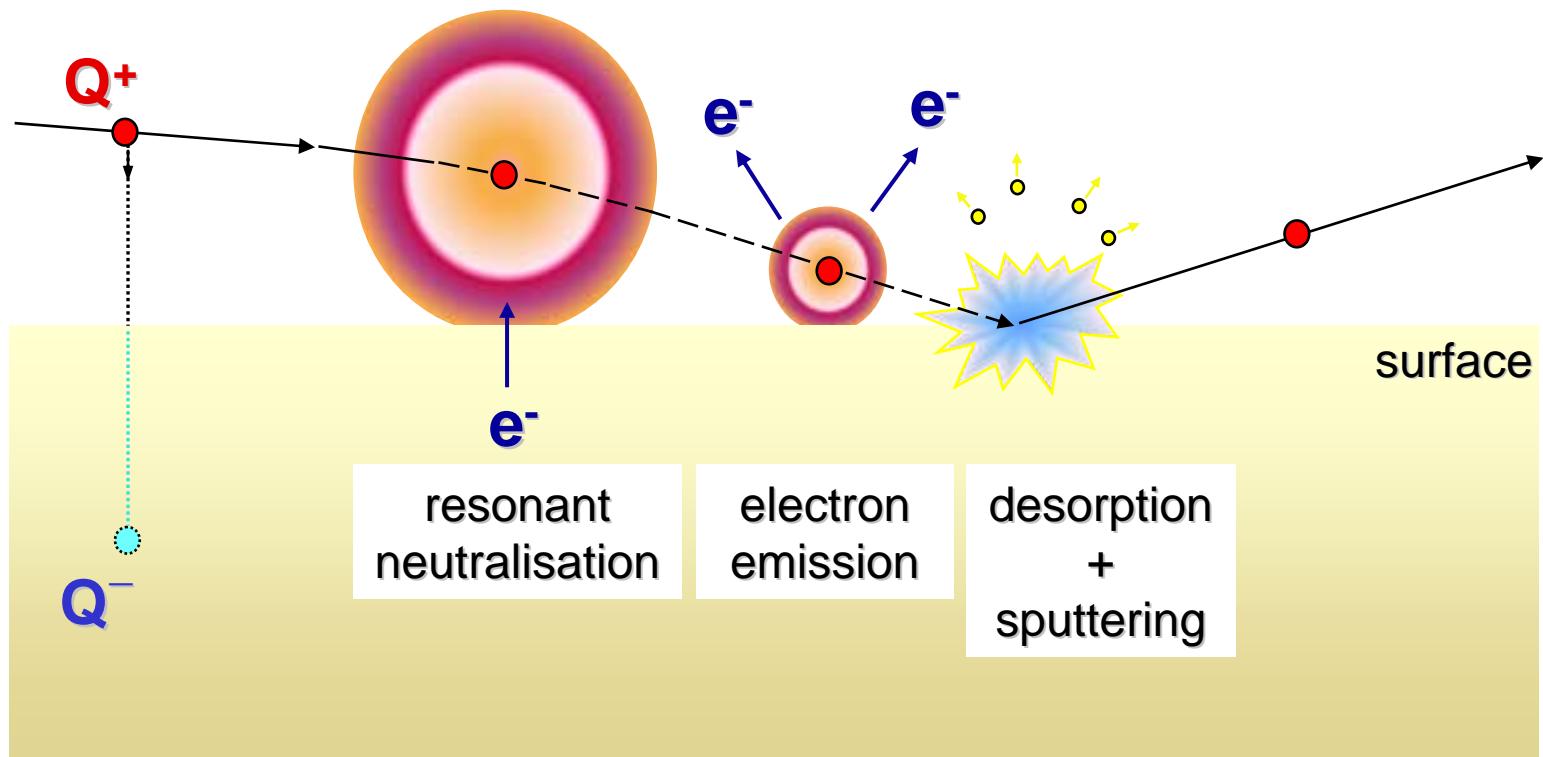
- **Fundamental aspects:**
 - response of matter to strong (DC) fields
 - metals vs. insulators
- **Scenarios for neutralization, relaxation and dissipation**
- **Applications to material science**
 - sputtering
 - nanostructuring
- **Outlook**

HCl-surface interaction scenario

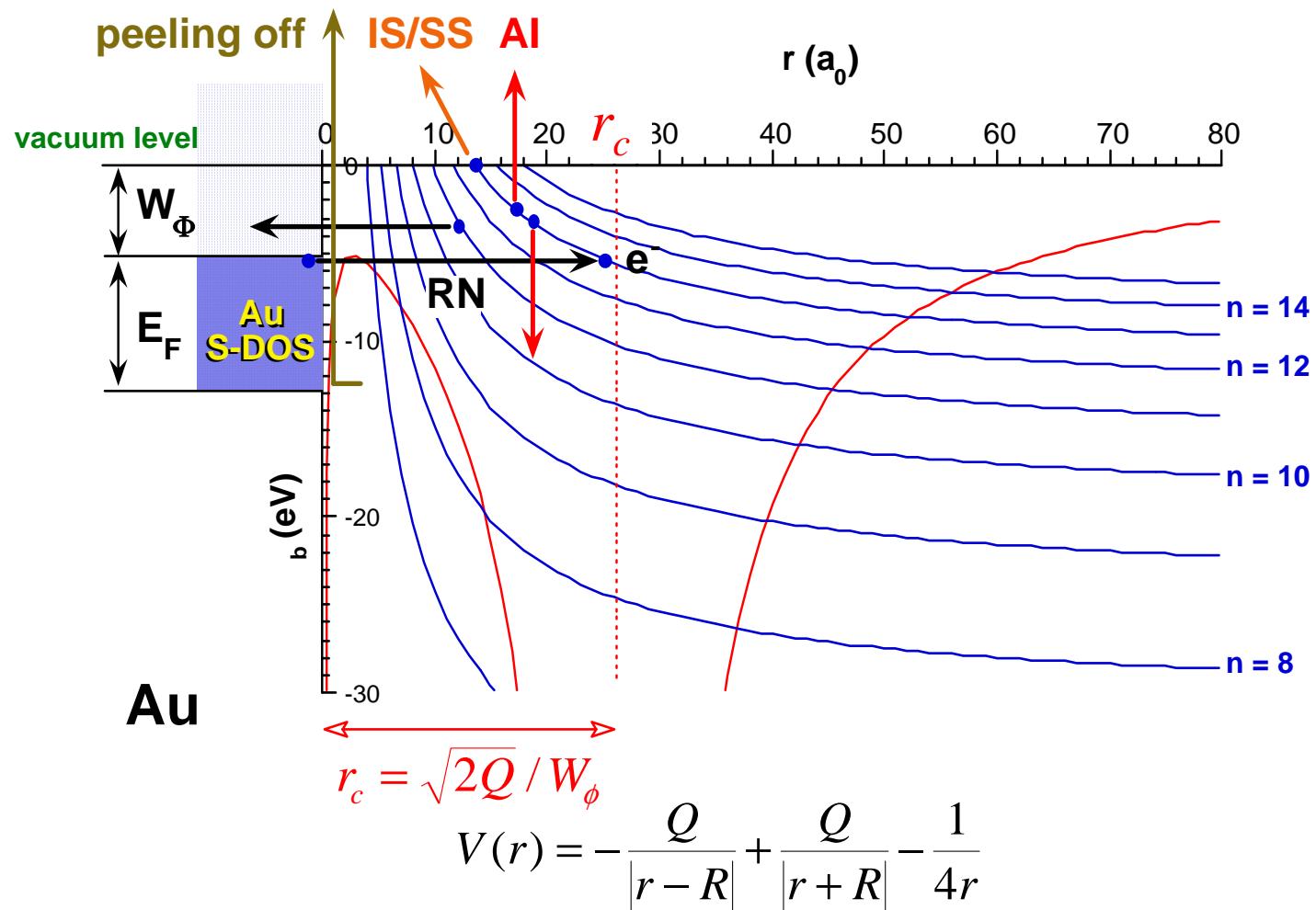
image charge
acceleration

“hollow atom”
formation & decay

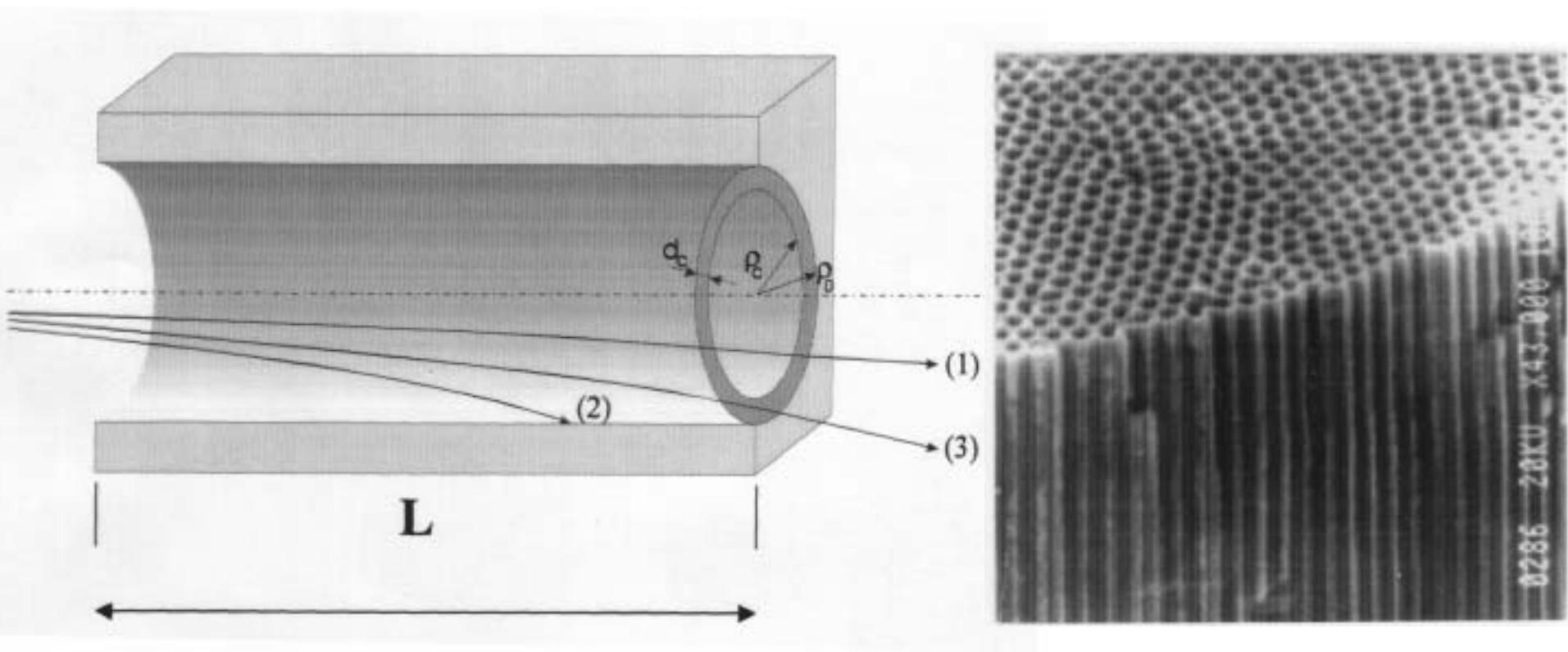
potential energy
deposition



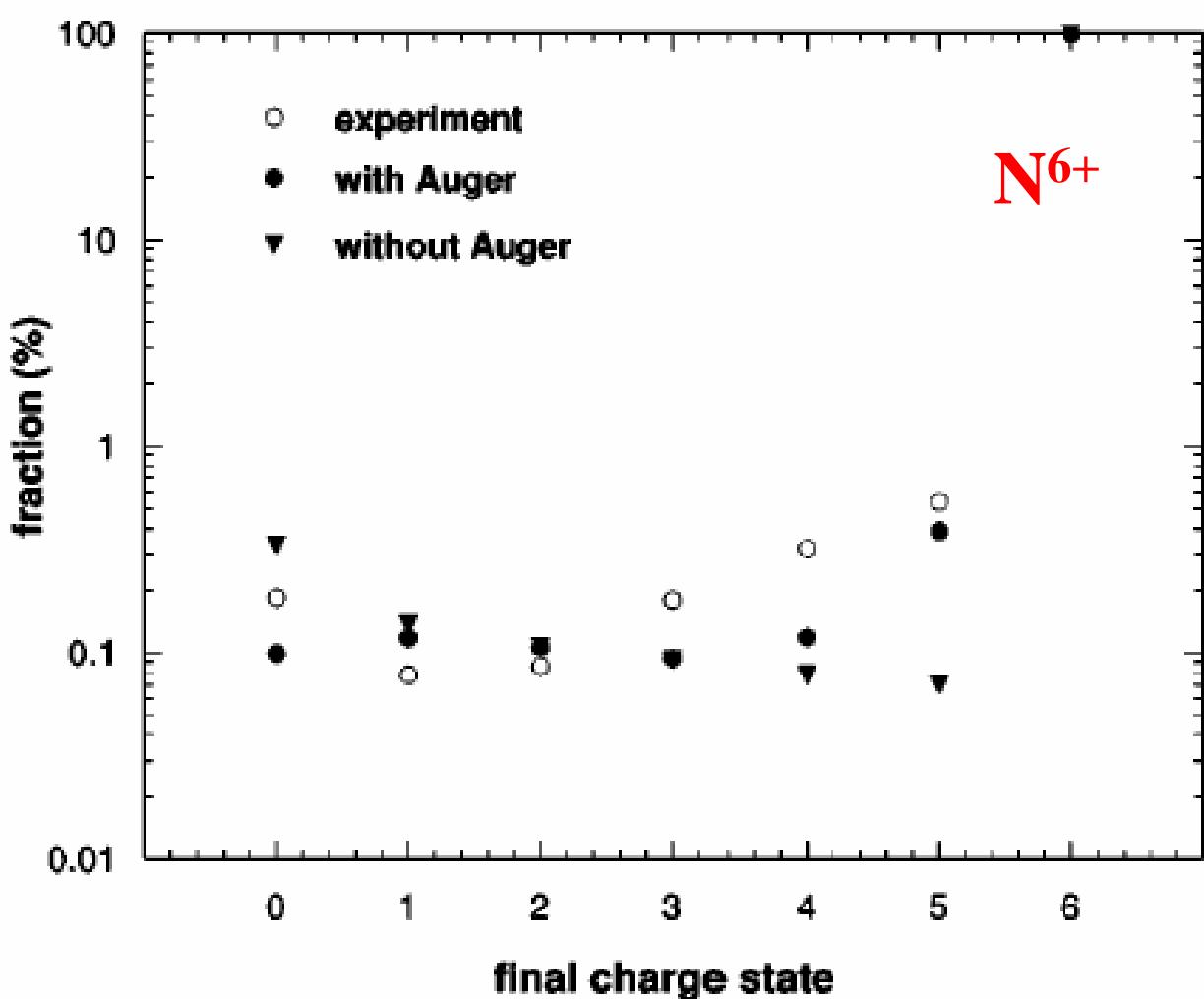
Classical Over-the-Barrier Model



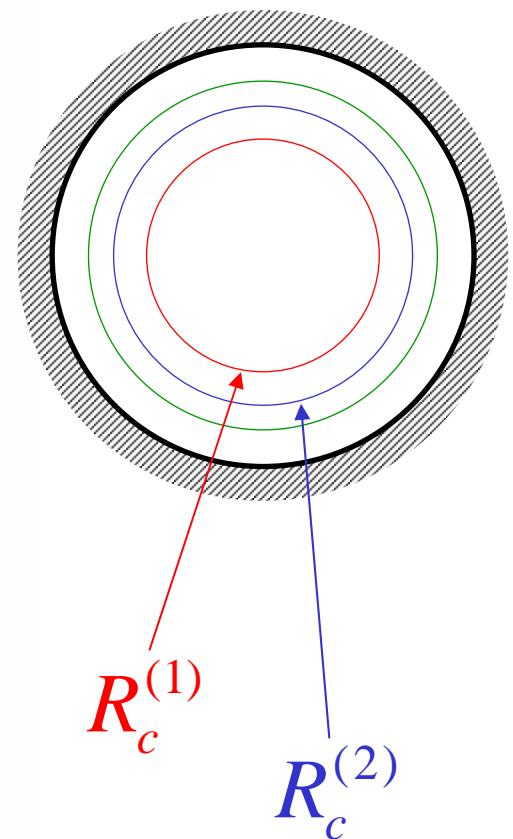
Tests for microcapillaries:



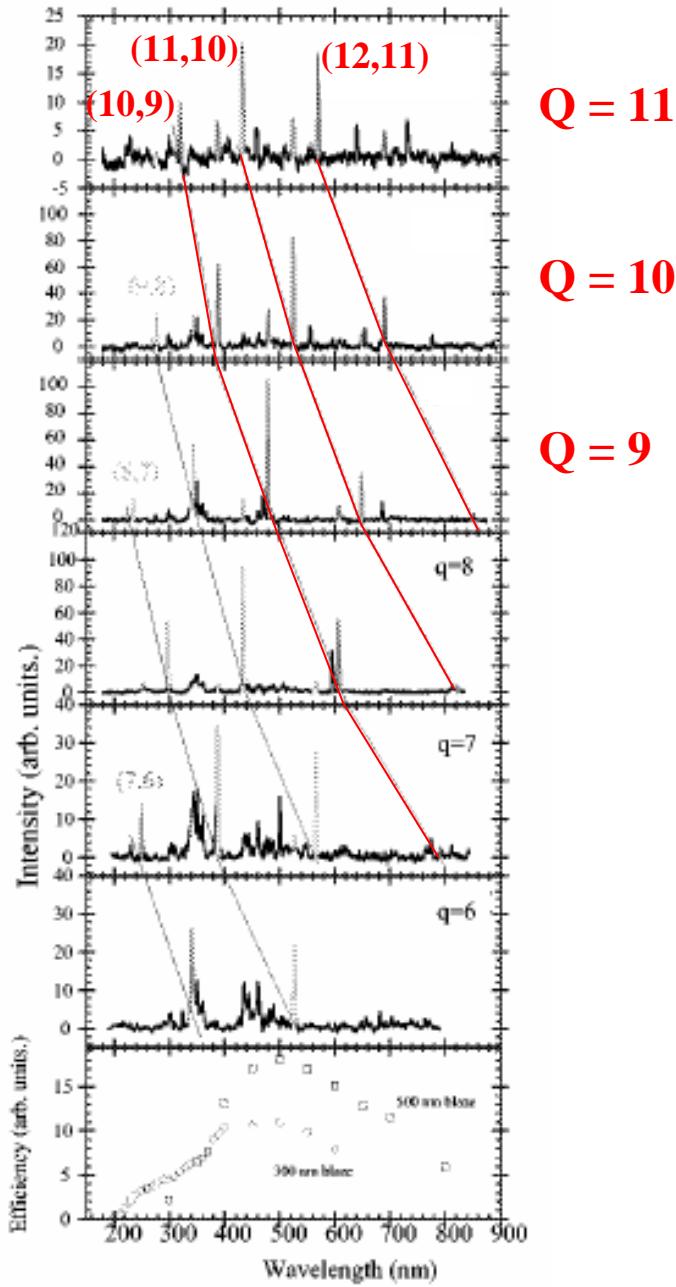
• Test of R_c



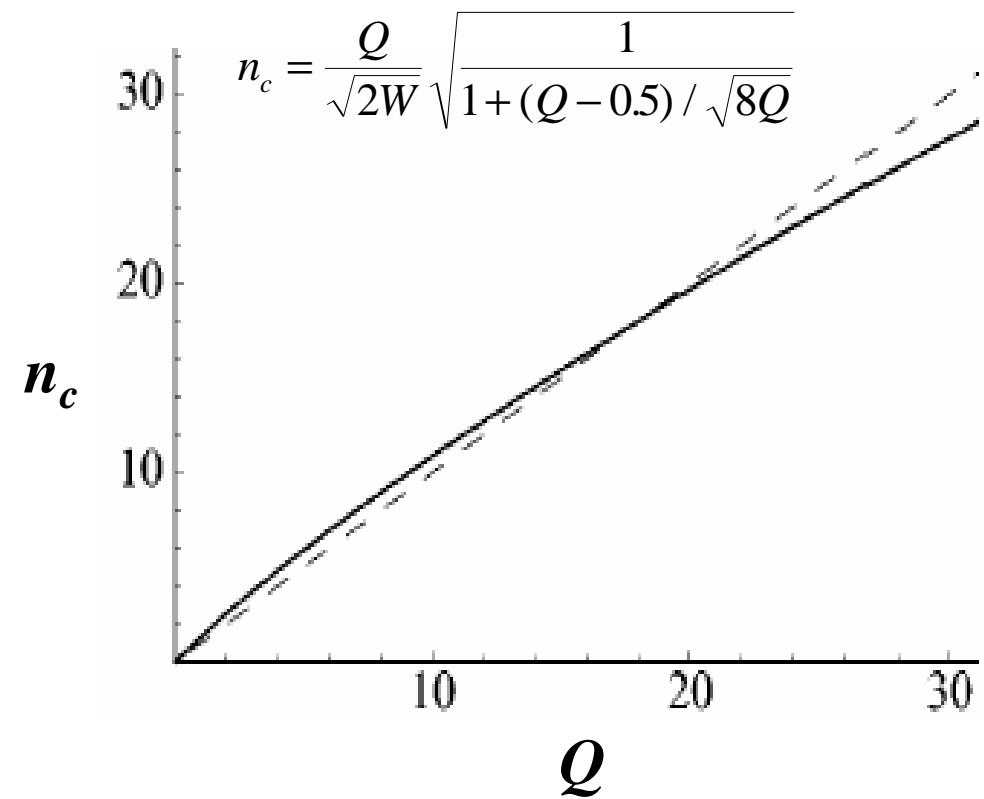
$$R_c = \sqrt{2Q} / W$$



Ninomiya et al., PRL (1997)

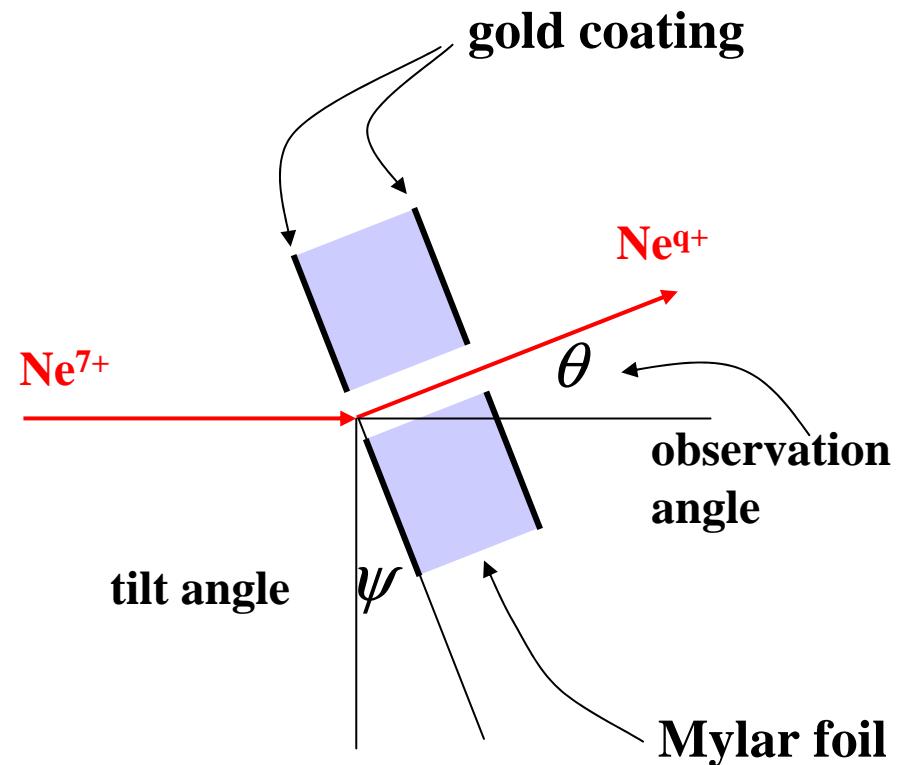
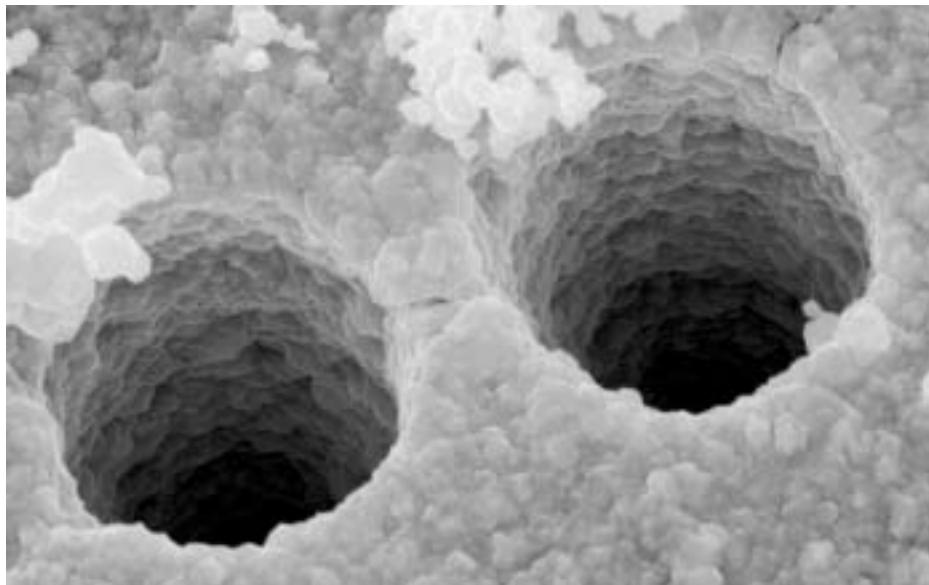


- Test of n_c

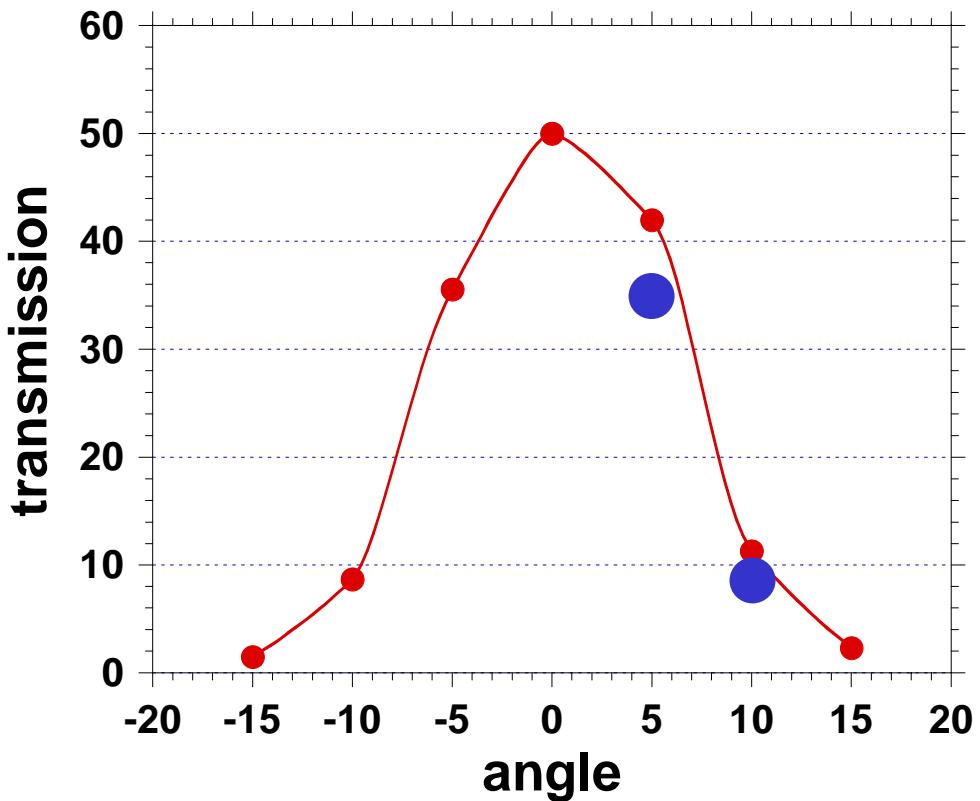


Morishita et al., submitted to PRL (2002)

Transmission through Mylar – Nanocapillaries

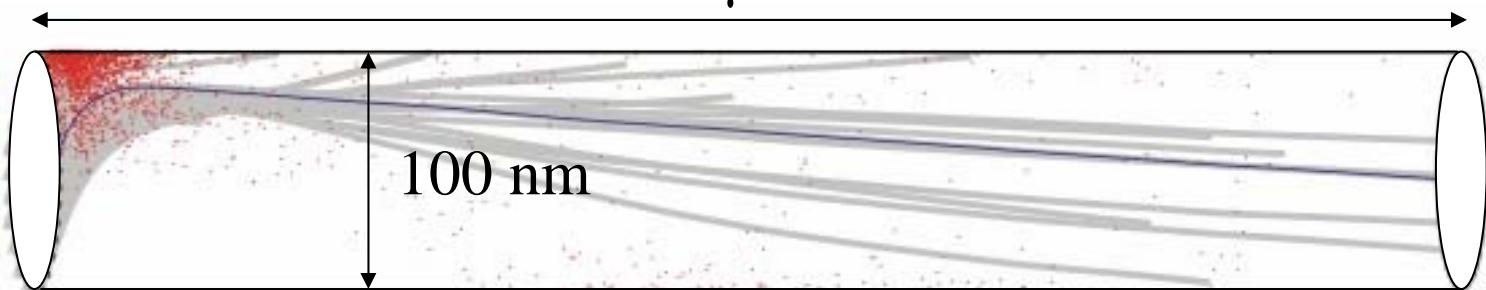


Stolterfoht et al., PRL 2002



10 μm

8 min



Applications to material science: ”soft“ sputtering

Neidhart et al. Phys. Rev. Lett. 74 (1995) 5280
Sporn et al. Phys. Rev. Lett. 79 (1997) 945

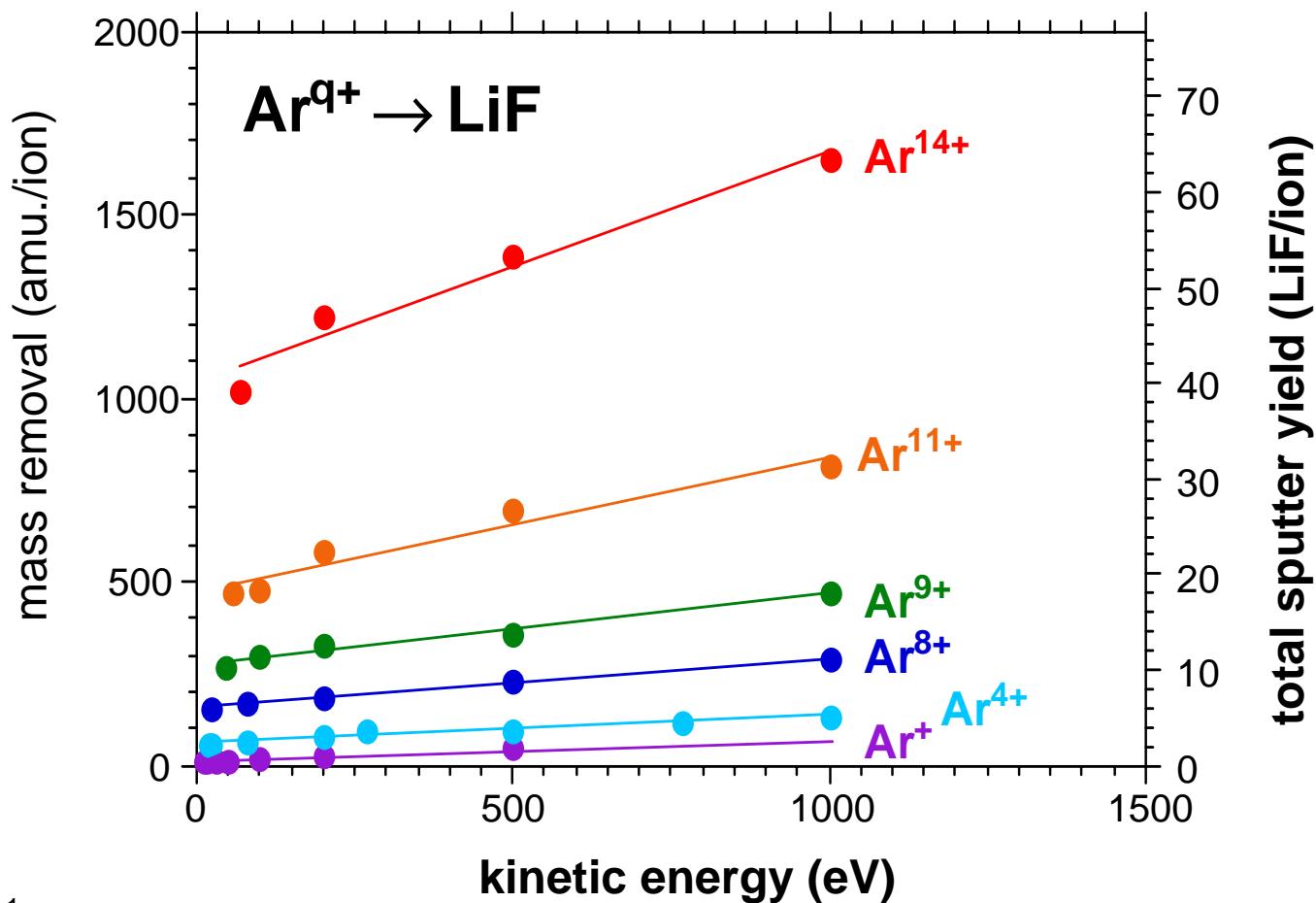


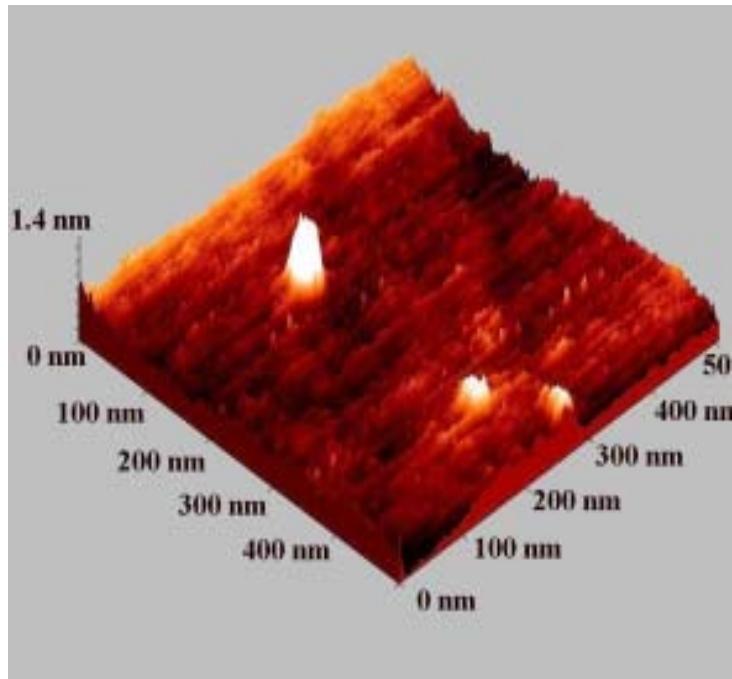
Fig. 1

Nanodefect - formation on insulators

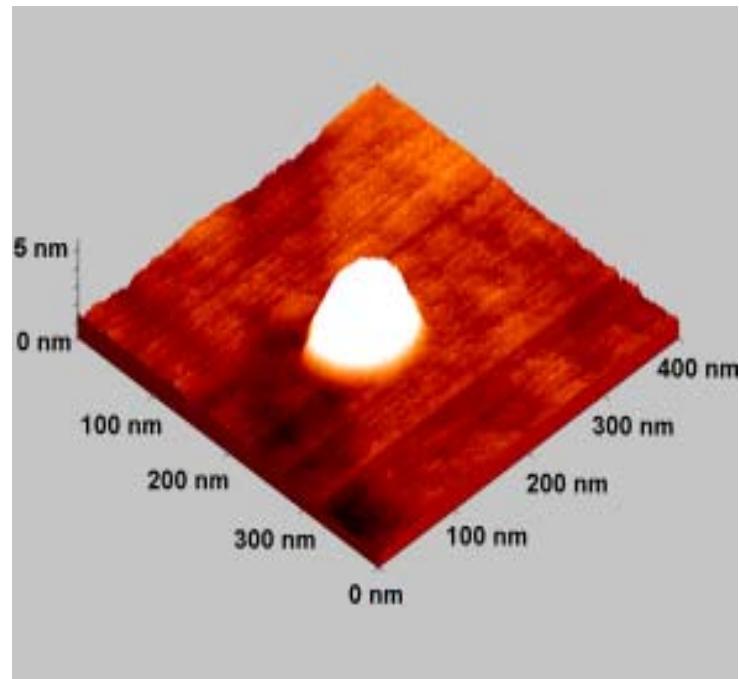
UHV - AFM, TU Wien

Gebeshuber et al. (2002)

Ar^+ (500 eV) on Al_2O_3

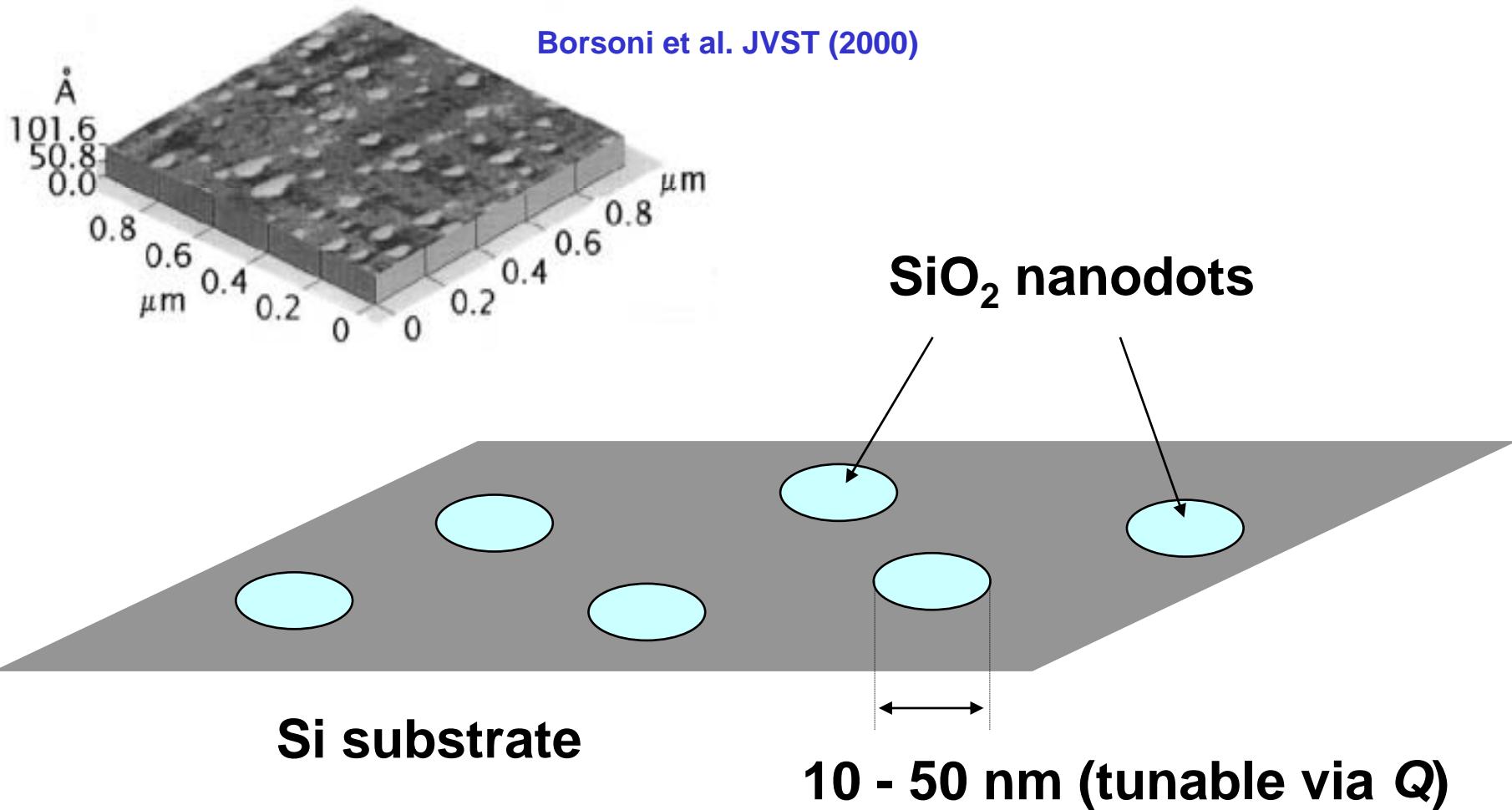


Ar^{7+} (500 eV) on Al_2O_3

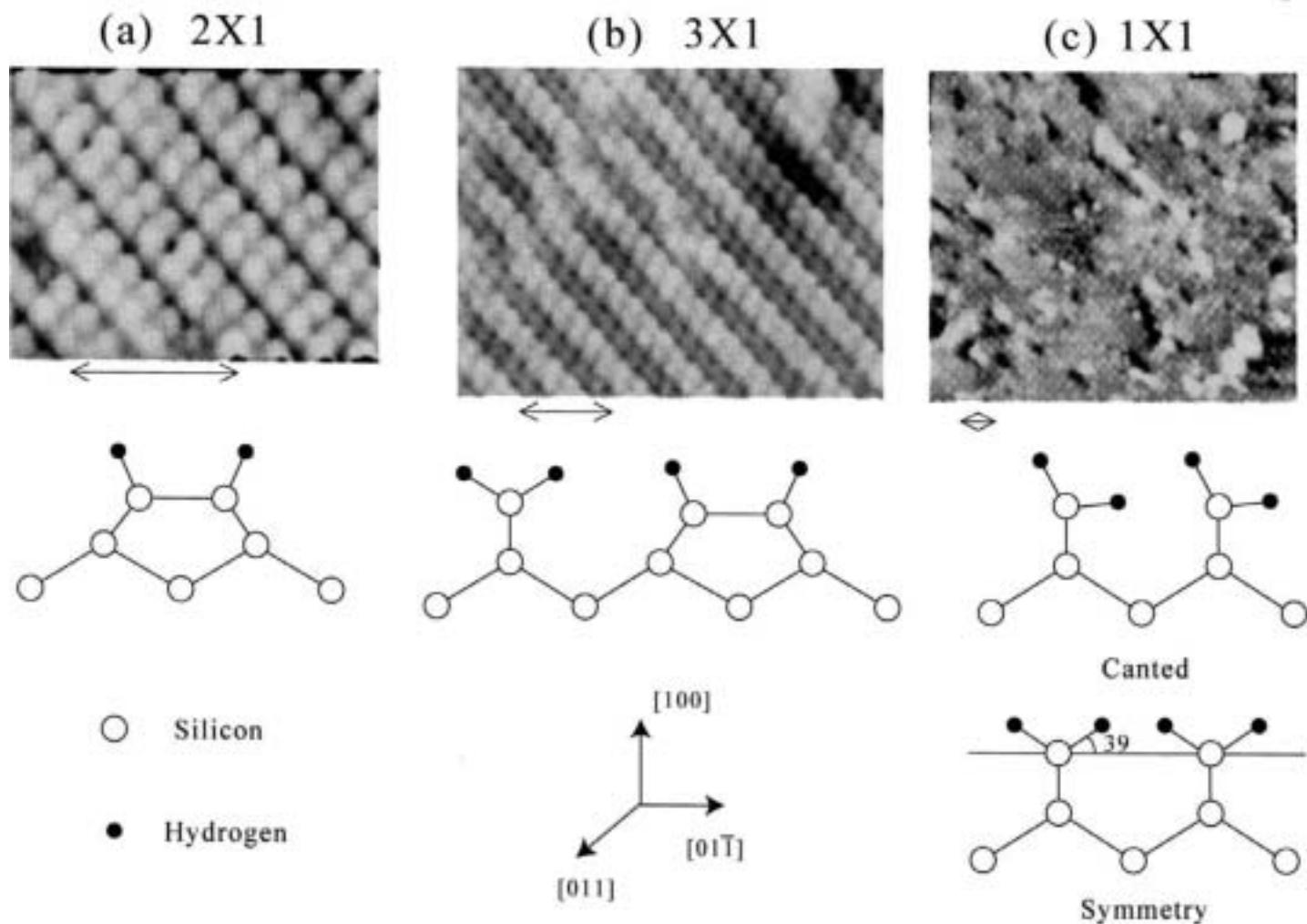


The observed defect size (both height and lateral) dimension increases with projectile charge state q

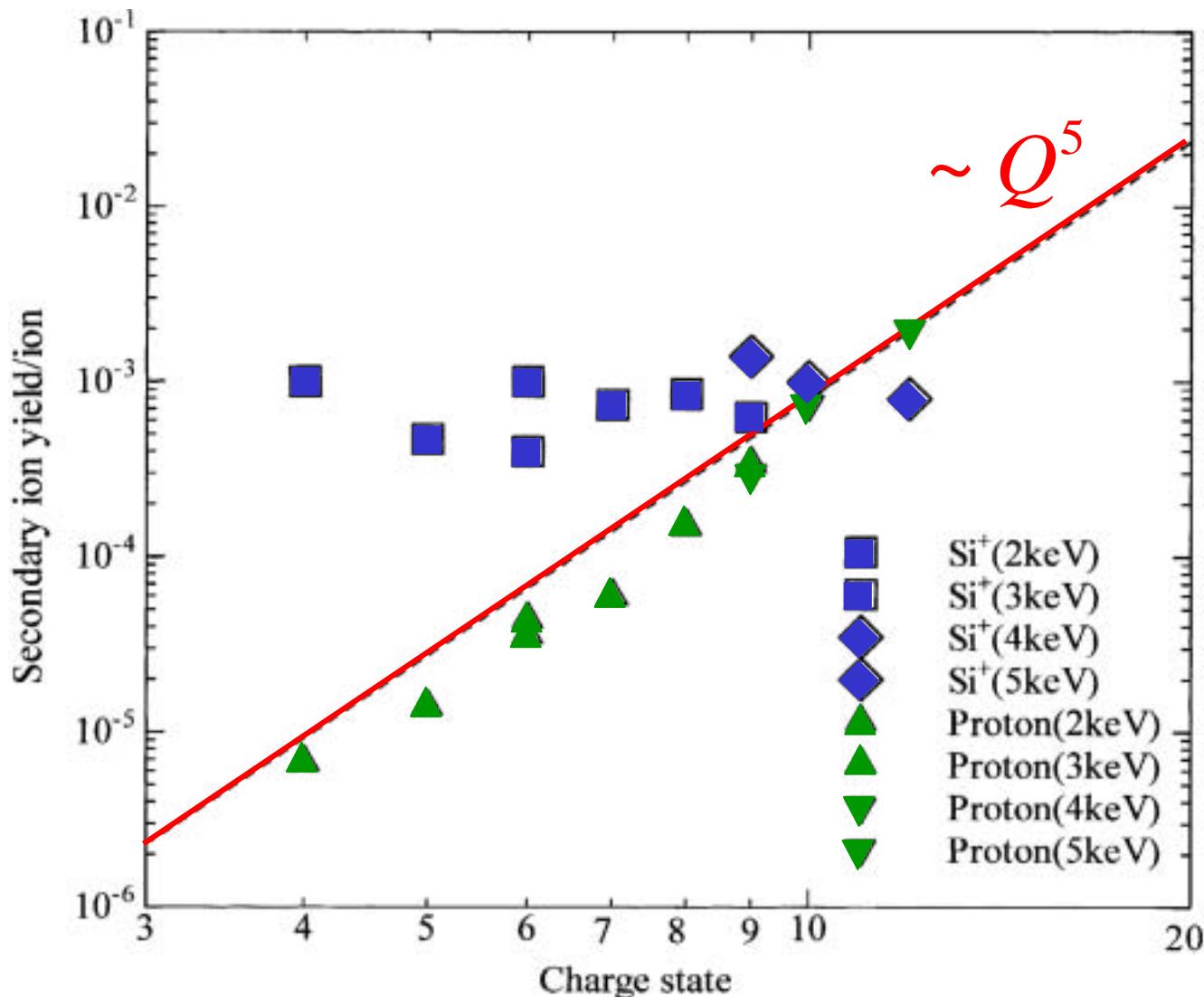
formation of ultra-shallow SiO_2 nanodots by HCl



Proton-sputtering by HCl from Hydrogen-terminated silicon

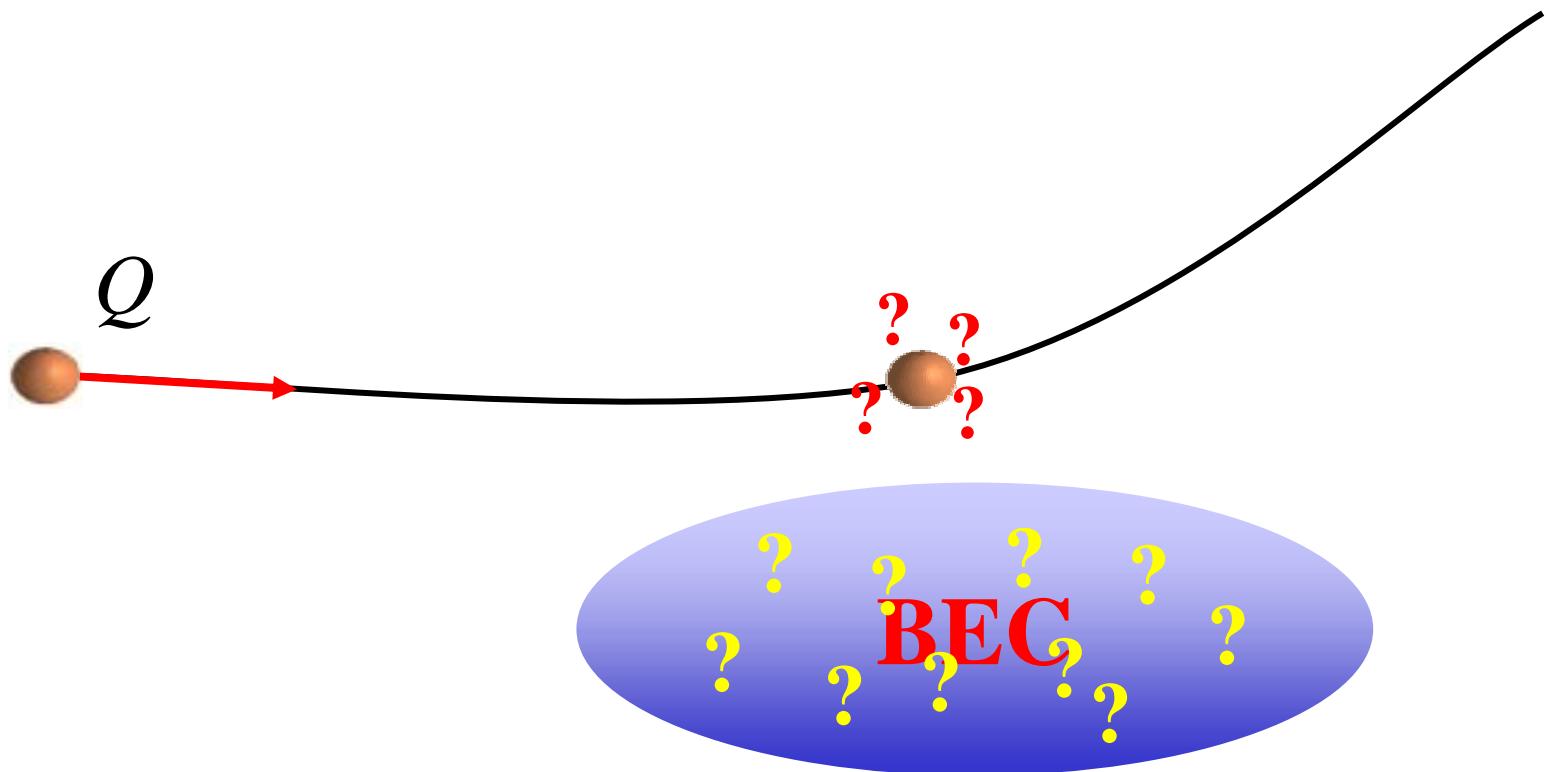


Strong Q dependence for H^+



Outlook: more exotic matter

Interaction of an HCl with a Bose-Einstein condensate (BEC)



Low-energy HCI important for

- linear and non-linear response of matter to strong (DC) fields
- material science:
 - soft sputtering
 - nanostructuring